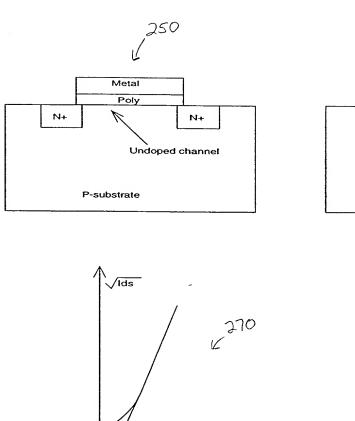
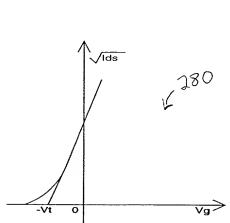


F1G.1



Native device

 $\overline{\mathsf{vg}}$



260

264

Ν+

Negative Vt implant

Metal

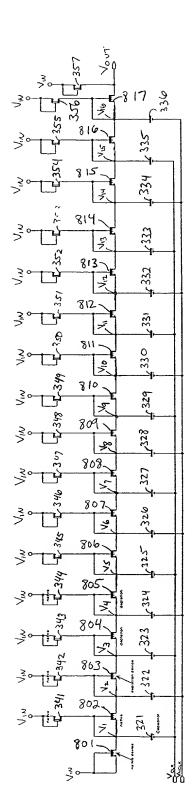
P-substrate

N+

262

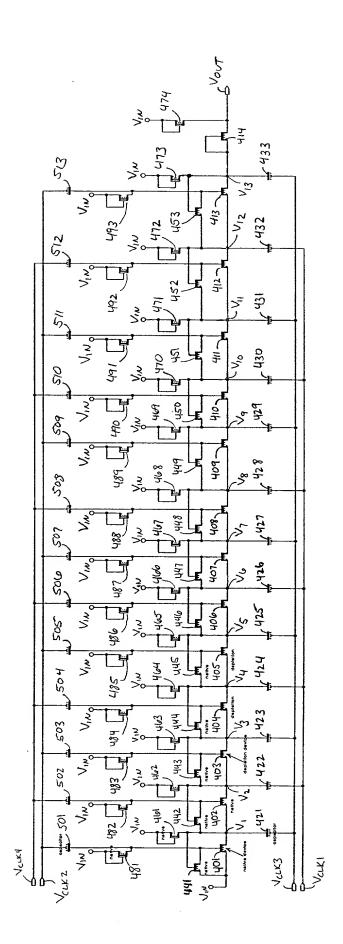
Depletion device

FIG. 2



7340

F1G. 3



下6.4

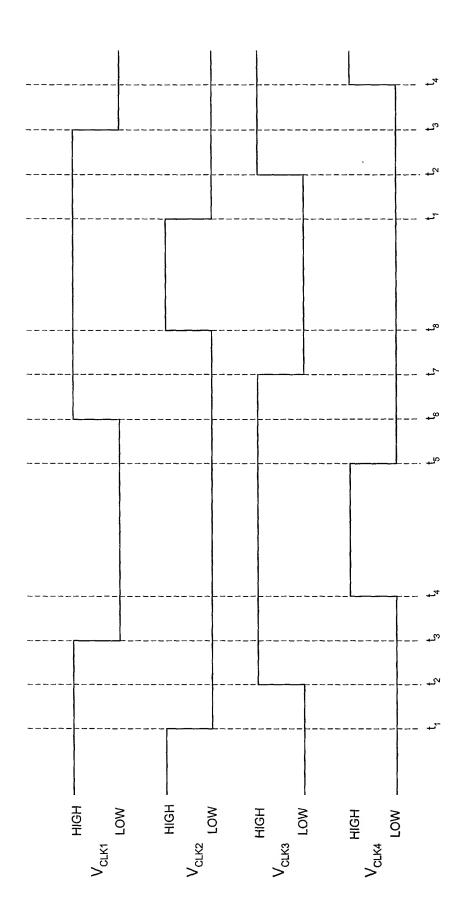


FIG. 5